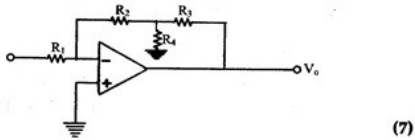


7. (a) Draw the circuit of differential amplifier. Find the output voltage. (6)

(b) Find the V_o of the following circuit :



(c) What is CMRR ? For a given op-amp CMRR = 10^4 and differential mode gain $A_d = 10^5$. What is the common mode gain A_c ? (7)

TEC-201

4

No. of Printed Pages—4

Roll No.

B. TECH. 1st - Year

SECOND SEMESTER EXAMINATION, 2007-2008

TEC-201 BASIC ELECTRONICS

Time : 3 Hours

Maximum Marks : 100

Note: Question No. 1 compulsory. Attempt any Five questions including Question No. 1. All questions carry equal marks.

1. Answer any 10 parts :

- Identify the components that constitute DC load in a BJT bias circuit.
- Write the expression for voltage gain in Differential amplifier.
- How can the output amplitude of phase shift oscillator be stabilized ?
- What is the need for cascade amplifier ?
- What is meant by ripple rejection ratio in voltage regulator ?
- Explain the difference between diffusion and transition capacitance.
- Explain the difference between BJT and FET.
- Sketch the output characteristics of CE transistor. Indicate the active, cut-off and saturation region.
- What is pinch-off voltage ?
- Sketch the circuit diagram of a Darlington pair.
- What is the effect of temperature on zener and avalanche breakdown ?
- Explain the difference between intrinsic and extrinsic semiconductors ?
- What is Thermal Runaway ?
- Calculate the closed loop gain for negative feedback amplifier when $A_v = 100000$ and $\beta = 1/100$. (20)

TEC-201

1

Turn Over

2. (a) Define α and β of a transistor and derive the relationship between them. (6)
- (b) Derive an expression for the dynamic resistance of a diode in forward bias and hence interpret graphically its variation with (i) Current (ii) Temperature. (6)
- (c) Explain the formation of potential barrier in a $p-n$ junction. Why is silicon preferred to germanium in the manufacturing of semiconductor device? (8)

Calculate the junction potential for a step graded Germanium $p-n$ junction. It has $N_D = 10^3 N_A$ and N_A corresponds to one atom, per 10^8 Germanium atoms. Assume $n_i = 2.5 \times 10^{13} / \text{cm}^3$ and atom density of Ge = 4.4×10^{22} atoms / cm^3 . (8)

3. (a) Describe the Hall effect. Find the magnitude of a Hall voltage V_H in n type germanium semiconductor having majority carrier concentration $N_D = 10^{17} / \text{cm}^3$, $d = 3$ mm, $E_x = 5$ V/cm, $B_z = 0.1$ wb/m², $\mu_n = 3800$ cm²/v-s. (6)
- (b) What is meant by Fermi level in semiconductors. Prove that the Fermi level in intrinsic semiconductor lies in the middle of energy band gap. (6)
- (c) What is law of mass action? A sample of silicon at $T = 300$ K is doped with boron at a concentration of $2.5 \times 10^{13} / \text{cm}^3$. What type of material it is? Find the concentration of holes and electrons. Assume $m = 1.5 \times 10^{10} / \text{cm}^3$. (8)

4. (a) What are hybrid parameters? Derive the h-parameters for a two port network. (7)

- (b) An operational amplifier is to have a voltage gain of 50. Determine the required values of the external resistors R_1 and R_2 if
(i) A non-inverting amplifier, (7)
(ii) An inverting amplifier is required. (7)
- (c) Realize the all other gates using NAND gate only. (6)

5. (a) Sketch a npn transistor CE amplifier circuit that uses fixed bias. Include a capacitor coupled signal source and load resistor. Explain the circuit operation. (10)

- (b) Draw the circuit of the transformer coupled class - A amplifier. Get the expression for the efficiency of class A-amplifier. List the applications. (10)

6. (a) Convert the following numbers :-

- (i) $(110110.000101)_2 = (\dots\dots\dots)_8$
(ii) $(1BE)_8 = (\dots\dots\dots)_{16} = (\dots\dots\dots)_2$
(iii) Solve without changing the base :
 $(432)_5$ (5)
 $- (124)_5$

- (b) Simplify the following expression using K-map method :

$$f(wxyz) = \sum m(1,4,8,12,13,15) + d(3,14) \quad (5)$$

- (c) Define the following terms :

- (i) Break-down voltage
(ii) Ripple factor
(iii) Pinch-off voltage
(iv) Drift and diffusion (10)